



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

Van Thillo et al.

Application No. 10/601,788

Filed: June 23, 2003

For: NOVEL SURFACTANTS

Art Unit: Unassigned

Examiner: Unassigned

CLAIM OF PRIORITY

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Dear Sir:

In accordance with the provisions of 35 USC 119, Applicants claim the priority of the following application:

Application No. 03101661.1, filed in Europe on June 6, 2003.

A certified copy of the above-listed priority document is enclosed.

Respectfully submitted,

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Date: July 22, 2003

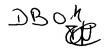
CERTIFICATE OF MAILING

I hereby certify that this CLAIM OF PRIORITY (along with any documents referred to as being attached or enclosed) is being deposited with the United States Postal Service on the date shown below with sufficient postage as first class mail in an envelope addressed to: Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450.

Date: 7 22 03

Virgnia Schiffre

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Europäisches **Patentamt**

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Office eur péen des brevets

Bescheinigung

Certificate

Attestation

Die angehefteten Unterlagen stimmen mit der ursprünglich eingereichten Fassung der auf dem nächsten Blatt bezeichneten europäischen Patentanmeldung überein.

The attached documents are exact copies of the European patent application conformes à la version described on the following page, as originally filed.

Les documents fixés à cette attestation sont initialement déposée de la demande de brevet européen spécifiée à la page suivante.

Patentanmeldung Nr.

Patent application No. Demande de brevet n°

03101661.1

Der Präsident des Europäischen Patentamts;

For the President of the European Patent Office

Le Président de l'Office européen des brevets p.o.

R C van Dijk

DEN HAAG, DEN THE HAGUE, LA HAYE, LE

11/06/03

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Blatt 2 der Besch inigung Sheet 2 of the certificate Page 2 de l'attestation

Anmeldung Nr.: Application no.: Demande n°:

03101661.1

Anmeldetag: Date of filing: Date de dépôt:

06/06/03

Anmelder: Applicant(s): Demandeur(s): AGFA-GEVAERT 2640 Mortsel BELGIUM

Bezeichnung der Erfindung: Title of the invention: Titre de l'invention: Novel surfactants

In Anspruch genommene Prioriät(en) / Priority(ies) claimed / Priorité(s) revendiquée(s)

Staat: State: Pays: Tag: Date: Date: Aktenzeichen: File no. Numéro de dépôt:

Internationale Patentklassifikation: International Patent classification: Classification internationale des brevets:

/

Am Anmeldetag benannte Vertragstaaten: Contracting states designated at date of filing: Etats contractants désignés lors du depôt:

AT/BG/BE/CH/CY/CZ/DE/DK/EE/ES/FI/FR/GB/GR/HU/IE/IT/LI/LU/MC/

Bemerkungen: Remarks: Remarques:

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DESCRIPTION

FIELD OF THE INVENTION

The present invention concerns 2-thioalkyl-benzimidazole-5-sulphonic acid and 2-thioalkyl-benzimidazole-6-sulphonic acid compounds and their use as surfactants.

BACKGROUND OF THE INVENTION

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US 2,053,822 discloses a process for the manufacture of sulphonic acids, consisting in treating with sulphonating agents imidazole derivatives having the atom grouping

$$R$$
 N
 R
 R
 R

in which R represents a carbocyclic aromatic radical containing at the most 10 carbon atoms, R₁ represents an alkyl radical containing at least 7 carbon atoms and R₂ is a member selected from the group consisting of hydrogen and alkyl. None of the alkylating agents cited contains an aromatic group i.e. benzyl chloride is apparently not included. The aromatic nucleus R may comprise substituents, for example, sulpho groups. The 2-substituent may also be a methoxy-, ethoxy-, mercapto- or thioalkyl- group. US 2,053,822 further discloses that new imidazoles are characterized by the atom grouping

$$\mathbb{R}_{N}^{N}$$

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wherein the radical R represents a sulphonated aromatic radical, wherein further the nature of the μ -substituent follows from the above enumerations, and wherein at least one of the two nitrogen atoms is linked with a radical R₁. The examples disclose the reaction of dodecyl chloride, 2-chloroacetic acid dodecyl ester with μ -heptadecyl-benzimidazole followed by sulphonation.

Thermography is an image-forming process including a heating step and hence includes photothermography in which the image-forming process includes image-wise exposure and direct thermal processes in which the image-forming process includes an image-wise

heating step. In direct thermal printing a visible image pattern is produced by image-wise heating of a recording material.

US 3,704,130 discloses a method of preparing a photographic fine-grain silver halide emulsion, which comprises the step of precipitating the silver halide in an aqueous hydrophilic colloid medium in the presence of a compound corresponding to the following general formula: Z-A-X, wherein: each of Z and X (the same or different) stands for a heterocycle or a heterocycle with fused-on ring, said heterocycle comprising the moiety =N-, and A stands for a chemical bond, alkylene, alkylene interrupted by oxygen or -N(R)-wherein R = hydrogen or alkyl comprising at most 4 C-atoms, arylene, alkenylene, -S-alkylene-S- or -S-alkylene, the alkylene groups of which can be interrupted by oxygen or -N(R)- wherein R has the same significance as above; said compound being present in an amount sufficient to restrain growth of silver halide grains. US 3,704,130 discloses the following 2-alkylthio-benzimidazole-6-sulphonic acid compounds as Compound 7:

$$\begin{array}{c|c} & & & \\ & & & \\ & & & \\ & & & \\ & & & \\ & & & \\ & & & \\ & & & \\ & & & \\ & & & \\ & & & \\ & & & \\ & & & \\ & & & \\ & & \\ & & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & & \\ & &$$

and Compound 9:

US 4,639,408 discloses a process for forming an image comprising a heating step wherein a silver halide light-sensitive photographic material is heated in the presence of a compound represented by formula (I)

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wherein X represents an atomic group completing a carbocyclic aromatic ring or a heterocyclic aromatic ring; R^1 is selected from selected from groups represented by formulae (A), (B), and (C):

$$-SO_2-R^{11}$$
 (A)

$$-C (=0) - R^{11}$$
 (B)

$$-P (=0) R^{11} R^{12}$$

(C)

in which R^{11} and R^{12} each represents a substituted or unsubstituted alkyl group, a cycloalkyl group, a substituted or unsubstituted aryl group, a substituted or unsubstituted heterocyclic group, an alkoxy or 5 aryloxy group, an alkylthio or arylthio group, or a substituted or unsubstituted amino group, or R11 and R12 together form a 5-membered or 6-membered ring; R2 represents a group selected from the groups represented by R11; R1 and R2 together form a 5-membered or 6-membered ring; Q represents a hydrogen atom, an alkyl group, or an aryl group; 10 TIME represents a timing group; PUG represents a photographically useful group; and n represents 0 or an integer, photographic material contains a base or a base precursor. US 4,639,408 discloses the following 2-alkylthio-benzimidazole-6sulphonic acid compounds as Compound (8):

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Compound (14):

Compound (24):

Compound 25:

and Compound 29:

$$C1$$
 O_2
 O_2
 O_3
 O_4
 O_4

Surfactants with excellent latex-stabilizing properties, which enhance the adhesion of hydrophilic layers to hydrophobic supports, such as polyethylene terephthalate and hydrophobic thermosensitive elements of substantially light-insensitive thermographic recording materials, which are photographically inactive, which do not contain photographically inactive impurities and which is compatible with image-wise heating with a thermal head when incorporated into the outermost layer of substantially light-insensitive thermographic recording materials.

ULTRAVON™ W, an anionic alkyl-,benzyl-benzimidazole-sulfonic acid surfactant produced by Ciba, fulfils these requirements, except that being a mixture of at least 25 components it has variable properties and also often contains photographically active impurities, which have to be removed or rendered non-photographically active prior to use. Furthermore, it is no longer available.

ASPECTS OF THE INVENTION

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It is therefore an aspect of the present invention to provide a surfactant with excellent latex-stabilizing properties.

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It is therefore a further aspect of the present invention to provide a photographically inactive surfactant.

It is therefore also an aspect of the present invention to provide a photographically inactive surfactant without 5 photographically active impurities.

It is therefore also an aspect of the present invention to provide a surfactant, which enhances the adhesion of hydrophilic layers to hydrophobic supports.

It is therefore also an aspect of the present invention to provide a surfactant, which is compatible with image-wise heating with a thermal head when incorporated into the outermost layer of substantially light-insensitive thermographic recording materials.

Further aspects and advantages of the invention will become apparent from the description hereinafter.

SUMMARY OF THE INVENTION

It has been surprisingly found that a compound represented by formula (I):

$$\begin{array}{c|c}
& & & \\
& & & \\
M & & \\
M$$

a compound represented by formula (II):

or a mixture of at least one compound represented by formula (I) and at least one compound represented by formula (II), wherein M is hydrogen, an alkali atom or an ammonium group; R¹ is hydrogen, a

 $-CH_2)_mSO_3M$ group or a MO_3S group; R^2 is an alkyl-, alkenyl- or alkynyl- group having 6 to 25 carbon atoms; and m is an integer between 1 and 5; exhibits excellent latex-stabilizing properties, enhances the adhesion of hydrophilic layers to hydrophobic supports, such as polyethylene terephthalate and hydrophobic thermosensitive

elements of substantially light-insensitive thermographic recording is photographically materials, inactive and does not contain photographically inactive impurities. Furthermore, outermost layers of substantially light-insensitive thermographic recording materials 5 containing compounds represented by formula (I), compounds represented by formula (II) or mixtures of at least one compound represented by formula (I) with at least one compound represented by formula (II) in which n is 12 to 24 surprisingly exhibit compatibility regarding transport properties with image-wise heating with a thermal head.

Aspects of the present invention are realized by a compound represented by formula (I):

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a compound represented by formula (II):

or a mixture of at least one compound represented by formula (I) with at least one compound represented by formula (II), wherein M is hydrogen, an alkali atom or an ammonium group; R^1 is hydrogen, a

 $-(CH_2)_mSO_3M$ group or a group; R^2 is an alkyl-, alkenyl- or alkynyl- group having 6 to 25 carbon atoms; and m is an integer between 1 and 5.

Aspects of the present invention are also realized by the use of at least one compound represented by the above-mentioned formula (I), at least one compound represented by the above-mentioned formula (II) or a mixture of at least one compound represented by the above-mentioned formula (I) and at least one compound represented by the above-mentioned formula (II) as a surfactant.

Aspects of the present invention are also realized by a photographic material comprising a support and at least one layer 30 containing photosensitive silver halide, characterized in that said

photographic material contains at least one compound represented by the above-mentioned formula (I), at least one compound represented by the above-mentioned formula (II) or a mixture of at least one compound represented by the above-mentioned formula (I) and at least one compound represented by the above-mentioned formula (II).

Preferred embodiments of the present invention are disclosed in the detailed description of the invention.

DETAILED DESCRIPTION OF THE INVENTION

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Definitions

The terms alkyl, alkenyl and alkynyl mean an aliphatic hydrocarbon group and all variants possible for each number of carbon atoms in the group i.e. the group can be a straight chain or a branched group. For example for a three carbon atom alkyl group: n-propyl and isopropyl; for a four carbon atom alkyl group: n-butyl, isobutyl and tertiary-butyl; for a five carbon atom alkyl group: n-pentyl, 1,1-dimethyl-propyl, 2,2-dimethylpropyl and 2-methyl-butyl. Branched alkyl groups with Guerbet groups are particularly suitable e.g. -CH2-CH[-(CH2)9-CH3]-(CH2)11-CH3, -CH2-CH[-(CH2)8-CH3]-(CH2)10-CH3, -CH2-CH[-(CH2)7-CH3]-(CH2)9-CH3, -CH2-CH[-(CH2)6-CH3]-(CH2)8-CH3, -CH2-CH[-(CH2)3-CH3]-(CH2)5-CH3.

The terms thioalkyl-, thioalkenyl- and thioalkynyl-group mean a group consisting of a sulphur atom bonded to an alkyl-, alkenyl- or alkynyl- group, which is bonded via the sulphur atom to the entity to which the group is bonded.

The term sulphoalkyl group means an alkyl group substituted 30 with a sulphonic acid group.

The term "tautomeric with" means that the two compounds interchange rapidly with one another in a liquid or dissolved state.

2-thioalkyl-benzimidazole-sulphonic acid compounds

According to a first embodiment of the compound, according to the present invention, R^1 is a -(CH₂)_mSO₃M group and R^2 is an alkyl, alkenyl or alkynyl group having 12 to 16 carbon atoms.

According to a second embodiment of the compound, according to the present invention, R^1 is a -(CH₂)₄SO₃M group and R^2 is an alkyl, alkenyl or alkynyl group having 12 to 16 carbon atoms.

According to a third embodiment of the compound, according to 5 the present invention, R^1 is a -(CH₂)₄SO₃M group and n is and R^2 is an alkyl, alkenyl or alkynyl group having 12 to 24 carbon atoms.

Suitable 2-thioalkyl-benzimidazole-sulphonic acid compounds, according to the present invention, are:

Compound nr		
01	2-thiododecyl-benzimidazole-5-sulphonic acid (tautomeric with 03)	HO ₃ S — H N S — C ₁₂ H ₂₅
02	2-thiododecyl-benzimidazole-5- sulphonic acid sodium salt (tautomeric with 04)	
03	2-thiododecyl-benzimidazole-6-sulphonic acid (tautomeric with 01)	
04	2-thiododecyl-benzimidazole-6- sulphonic acid sodium salt (tautomeric with 02)	
05	2-thiopentadecyl-benzimidazole- 5-sulphonic acid (tautomeric with 07)	
· 06	2-thiopentadecyl-benzimidazole- 5-sulphonic acid sodium salt (tautomeric with 08)	
07	2-thiopentadecyl-benzimidazole- 6-sulphonic acid (tautomeric with 05)	
08	2-thiopentadecyl-benzimidazole- 6-sulphonic acid sodium salt (tautomeric with 06)	
09	2-thiohexadecyl-benzimidazole-5-sulphonic acid (tautomeric with 11)	
10	2-thiohexadecyl-benzimidazole-5- sulphonic acid sodium salt (tautomeric 12)	
11	2-thiohexadecyl-benzimidazole-6-sulphonic acid (tautomeric with 09)	
12	2-thiohexadecyl-benzimidazole-6-sulphonic acid sodium salt	

	(tautomeric with 10)	
13	2-thioheptadecyl-benzimidazole-	
	5-sulphonic acid (tautomeric	
	with 15)	
14	2-thioheptadecyl-benzimidazole-	
	5-sulphonic acid sodium salt	
	(tautomeric with 16)	
15	2-thioheptadecyl-benzimidazole-	
	6-sulphonic acid (tautomeric	
	with 13)	
16	2-thioheptadecyl-benzimidazole-	
	6-sulphonic acid sodium salt	
	(tautomeric with 14)	
17	2-thiododecyl,3-sulphopentyl-	
	benzimidazole-5-sulphonic acid	
18	2-thiododecyl,3-sulphopentyl-	
	benzimidazole-5-sulphonic acid	
	sodium salt	
19	2-thiododecyl,3-sulphopentyl-	
	benzimidazole-6-sulphonic acid	
20	2-thiododecyl,3-sulphopentyl-	
	benzimidazole-6-sulphonic acid	
	sodium salt	
21	2-thiopentadecyl,3-sulpho-	
	pentyl-benzimidazole-5-sulphonic	
	acid	
22	2-thiopentadecyl,3-sulphopentyl-	
	benzimidazole-5-sulphonic acid	
	potassium salt	
23	2-thiopentadecyl,3-sulpho-	
	pentyl-benzimidazole-6-sulphonic	
	acid	
24	2-thiopentadecyl, 3-sulphopentyl-	
	benzimidazole-6-sulphonic acid	
	potassium salt	
25	2-thiohexadecyl, 3-sulpho-pentyl-	
	benzimidazole-5-sulphonic acid	
26	2-thiohexadecyl,3-sulphopentyl-	
	benzimidazole-5-sulphonic acid	
	potassium salt	
27	2-thiohexadecyl, 3-sulpho-pentyl-	
	benzimidazole-6-sulphonic acid	
28	2-thiohexadecyl,3-sulphopentyl-	
	benzimidazole-6-sulphonic acid	
	potassium salt	
29	2-thioheptadecyl,3-sulpho-	
	pentyl-benzimidazole-5-sulphonic	
	acid	

30	2-thioheptadecyl, 3-sulphopentyl-	
	benzimidazole-5-sulphonic acid	
	potassium salt	
31	2-thioheptadecyl,3-sulpho-	
	pentyl-benzimidazole-6-sulphonic	
	acid	
32	2-thioheptadecyl,3-sulphopentyl-	
	benzimidazole-6-sulphonic acid	
	potassium salt	
33	2-thiododecyl,3-sulphobutyl-	
	benzimidazole-5-sulphonic acid	
34	2-thiododecyl,3-sulphobutyl-	
	benzimidazole-5-sulphonic acid	
	potassium salt	
35	2-thiododecyl,3-sulphobutyl-	
	benzimidazole-6-sulphonic acid	
36	2-thiododecyl,3-sulphobutyl-	HQ
	benzimidazole-6-sulphonic acid	0=8=0
	sodium salt]
		N S
		Na [†]
		HO 0
37	2-thiododecyl,3-sulphobutyl-	
-	benzimidazole-6-sulphonic acid	
	potassium salt	
38	2-thiopentadecyl, 3-sulpho-butyl-	
	benzimidazole-5-sulphonic acid	
39	2-thiopentadecyl, 3-sulphobutyl-	
	benzimidazole-5-sulphonic acid	
	potassium salt	
40	2-thiopentadecyl, 3-sulpho-butyl-	
	benzimidazole-6-sulphonic acid	
41	2-thiopentadecyl, 3-sulphobutyl-	
	benzimidazole-6-sulphonic acid	
	potassium salt	
42	2-thiohexadecyl, 3-sulpho-butyl-	
•	benzimidazole-5-sulphonic acid	
43	2-thiohexadecyl, 3-sulphobutyl-	
	benzimidazole-5-sulphonic acid	
	sodium salt	
44	2-thiohexadecyl, 3-sulpho-butyl-	
***	benzimidazole-5-sulphonic acid	
		ı

	potassium salt	
45	2-thiohexadecyl, 3-sulphobutyl-	
10	benzimidazole-6-sulphonic acid	
46	2-thiohexadecyl, 3-sulphobutyl-	но
10	benzimidazole-6-sulphonic acid	0=\$=0
	sodium salt	, ,
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		N S 1 1
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		$\bigcup_{\Omega_2} \longrightarrow \bigcup_{\Omega_2} \bigcup_$
		S
		но
47	2-thiohexadecyl, 3-sulphobutyl-	
	benzimidazole-6-sulphonic acid	
	potassium salt	
48	2-thioheptadecyl, 3-sulpho-butyl-	
	benzimidazole-5-sulphonic acid	
49	2-thioheptadecyl,3-sulphobutyl-	
	benzimidazole-5-sulphonic acid	
	sodium salt	
50	2-thioheptadecyl, 3-sulpho-butyl-	
	benzimidazole-5-sulphonic acid	
	potassium salt	
51	2-thioheptadecyl, 3-sulpho-butyl-	
	benzimidazole-6-sulphonic acid	
52	2-thioheptadecyl,3-sulphobutyl-	
	benzimidazole-6-sulphonic acid	
	potassium salt	
53	2-thiododecyl,3-sulphopropyl-	
	benzimidazole-5-sulphonic acid	
54	2-thiododecyl,3-sulphopropyl-	
	benzimidazole-5-sulphonic acid	
	sodium salt	
55	2-thiododecyl, 3-sulphopropyl-	
	benzimidazole-5-sulphonic acid	
	potassium salt	
56	2-thiododecyl,3-sulphopropyl-	
	benzimidazole-6-sulphonic acid	
57	2-thiododecyl, 3-sulphopropyl-	
	benzimidazole-6-sulphonic acid	
F.	potassium salt	
58	2-thiododecyl, 3-sulphopropyl-	
	benzimidazole-6-sulphonic acid	
	sodium salt	
59	2-thiopentadecyl,3-sulpho-	

	<pre>propyl-benzimidazole-5-sulphonic acid</pre>	
60	2-thiopentadecyl,3-sulphopropyl-	
00	benzimidazole-5-sulphonic acid	
	potassium salt	
<u></u>		
61	2-thiopentadecyl,3-sulpho-	
	propyl-benzimidazole-6-sulphonic	
	acid	
62	2-thiopentadecyl, 3-sulphopropyl-	
	benzimidazole-6-sulphonic acid	
	potassium salt	
63	2-thiohexadecyl,3-sulpho-propyl-	
	benzimidazole-5-sulphonic acid	
64	2-thiohexadecyl,3-sulphopropyl-	
	benzimidazole-5-sulphonic acid	
	potassium salt	
65	2-thiohexadecyl,3-sulphopropyl-	
	benzimidazole-5-sulphonic acid	
	sodium salt	
· 66	2-thiohexadecyl,3-sulphopropyl-	
	benzimidazole-6-sulphonic acid	
67	2-thiohexadecyl,3-sulphopropyl-	
	benzimidazole-6-sulphonic acid	
	potassium salt	
68	2-thioheptadecyl,3-sulpho-	
	propyl-benzimidazole-5-sulphonic	
	acid	
69	2-thioheptadecyl,3-sulphopropyl-	
	benzimidazole-5-sulphonic acid	
	potassium salt	
70	2-thioheptadecyl,3-sulpho-	
	propyl-benzimidazole-6-sulphonic	
	acid	
71	2-thioheptadecyl, 3-sulphopropyl-	
	benzimidazole-6-sulphonic acid	
	potassium salt	
72	2-thiododecyl,3-sulphoethyl-	
	benzimidazole-5-sulphonic acid	
73	2-thiododecyl, 3-sulphoethyl-	
	benzimidazole-5-sulphonic acid	
	potassium salt	
74	2-thiododecyl, 3-sulphoethyl-	,
. .	benzimidazole-6-sulphonic acid	
75	2-thiododecyl, 3-sulphoethyl-	
, 5	benzimidazole-6-sulphonic acid	
	potassium salt	
76	2-thiopentadecyl, 3-sulpho-ethyl-	
70		
	benzimidazole-5-sulphonic acid	

77	2-thiopentadecyl,3-sulphoethyl-	
	benzimidazole-5-sulphonic acid	
	potassium salt	
78	2-thiopentadecyl, 3-sulpho-ethyl-	
	benzimidazole-6-sulphonic acid	
79	2-thiopentadecyl, 3-sulphoethyl-	
	benzimidazole-6-sulphonic acid	
	potassium salt	
80	2-thiohexadecyl, 3-sulpho-ethyl-	
	benzimidazole-5-sulphonic acid	
81	2-thiohexadecyl, 3-sulphoethyl-	
	benzimidazole-6-sulphonic acid	
82	2-thiohexadecyl, 3-sulphoethyl-	
	benzimidazole-6-sulphonic acid	
	potassium salt	
83	2-thioheptadecyl,3-sulpho-ethyl-	
	benzimidazole-5-sulphonic acid	
84	2-thioheptadecyl, 3-sulphoethyl-	
	benzimidazole-5-sulphonic acid	
	potassium salt	
85	2-thioheptadecyl, 3-sulpho-ethyl-	
	benzimidazole-6-sulphonic acid	
86	2-thioheptadecyl, 3-sulphoethyl-	
	benzimidazole-6-sulphonic acid	
	potassium salt	

 $-(CH_2)_mSO_3M$ group and groups can be incorporated into 2-alkyl- or 2-thioalkyl-benzimidazole-sulphonic acids by reaction with alkanesultones, such as 1,4-butanesultone and 1,3- propanesultone, and 3H-2,1-benzothiazole,1,1-dioxide (α -hydroxy-otoluenesulfonic acid- γ -sultone or o-tolyl sultone) respectively.

Photographic material

The photographic material may be developable with a conventional photographic developer or may be thermally developable i.e. the photographic material is a photothermographic material.

Photothermographic material

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According to a first embodiment of the photographic material, according to the present invention, the photothermographic material

is a photothermographic material in which the layer containing photosensitive halide is at least part of a photo-addressable thermally developable element, said thermally developable element further comprising a substantially light-insensitive organic silver salt, a reducing agent therefor in thermal working relationship therewith and a binder.

If the photographic material is a photothermographic material containing a substantially light-insensitive organic silver salt, for example a substantially light-insensitive silver salt of an organic carboxylic acid, the photosensitive silver halide present may be employed in a range of 0.1 to 100 mol percent; preferably, from 0.2 to 80 mol percent; particularly preferably from 0.3 to 50 mol percent; especially preferably from 0.5 to 35 mol %; and especially from 1 to 12 mol % of substantially light-insensitive organic silver salt. Furthermore, in such a material so-called insitu silver halide can be prepared by conversion of a substantially light-insensitive silver salt of an organic carboxylic acid with a non-fluoro halide ion source such as described in US 3,457,075, WO 97/48104 and WO 97/48105.

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Photosensitive silver halide

The photosensitive silver halide used the present invention may be any photosensitive silver halide such as silver bromide,

25 silver iodide, silver chloride, silver bromoiodide, silver chlorobromoiodide, silver chlorobromide etc. The silver halide may be in any form which is photosensitive including, but not limited to, cubic, orthorhombic, tabular, tetrahedral, octagonal etc. and may have epitaxial growth of crystals thereon.

According to a second embodiment of the photographic material, according to the present invention, the layer containing silver halide is a silver halide emulsion layer.

According to a third embodiment of the photographic material, according to the present invention, the layer containing silver so halide is a silver halide emulsion layer comprising cubic silver bromide or silver bromoiodide crystals with an amount of at most 3 mole% of iodide.

According to a fourth embodiment of the photographic material, according to the present invention, the layer containing silver 40 halide is a silver halide emulsion layer comprising monodisperse silver bromide or silver bromoiodide crystals. A monodisperse size

distribution is obtained when 95% of the grains have a size that does not deviate more than 30% from the average grain size.

Cubic crystals are especially preferred as they allow rapid processing. In principle the same is possible with flat tabular 5 crystals but, due to their heterogeneous silver halide grain distribution, their gradation is too low and due to the lightreflection of the developed silver which is situated at longer wavelengths the image tone is not neutral, but shifted to a reddish brown colour.

The silver bromide or silver bromoiodide emulsions used in accordance with this invention may be prepared by mixing the halide and silver salt solutions in partially or fully controlled conditions of temperature, concentrations, sequence of addition, and rates of addition. The silver halide is preferably precipitated 15 according to the double-jet method, in the presence of a colloid binder in a temperature-controlled vessel provided with a solution inlet and stirring unit.

A preferred precipitation technique is the double-jet method, wherein the silver ion concentration is controlled during the 20 precipitation and wherein the flow rate of the reacting solutions is enhanced as the precipitation proceeds, at such a rate that no renucleation appears. This method offers the possibility of obtaining well-defined crystals having a regular cubic habit within a short precipitation time. Preferred cubic silver bromide or 25 silver bromoioidide crystals have a crystal size between 0.1 and 0.4 μm and even more preferably between 0.30 and 0.35 μm for reasons of image tone of the developed silver halide crystals. As a result a high covering power of the developed grains is obtained.

The silver halide used in the present invention may be 30 employed without modification in the case of use in photothermographic materials, but for photographic emulsion materials and optionally in photothermographic material, however, it may be chemically sensitized with a chemical sensitizing agent such as a compound containing sulphur, selenium, tellurium etc., or 35 a compound containing gold, platinum, palladium, iron, ruthenium, rhodium or iridium etc., a reducing agent such as a tin halide etc., or a combination thereof.

Details of these procedures are described in T. H. James, "The Theory of the Photographic Process", Fourth Edition, Macmillan 40 Publishing Co. Inc., New York (1977), Chapter 5, pages 149 to 169, in "Chimie et Physique Photographique" by P. Glafkides, in "Photographic Emulsion Chemistry" by G.F. Duffin, in "Making and

Coating Photographic Emulsion" by V.L. Zelikman et al, and in "Die Grundlagen der Photographischen Prozesse mit Silberhalogeniden" edited by H. Frieser and published by Akademische Verlagsgesellschaft (1968). As described in this literature chemical sensitization may be carried out by effecting the ripening in the presence of small amounts of compounds containing sulphur e.g. thiosulphate, thiocyanate, thioureas, sulphites, mercapto compounds, and rhodamines. The emulsions may also be sensitized by gold-sulphur ripeners or by means of reducing agents e.g. tin compounds as described in GB-A 789,823, amines, hydrazine derivatives, formamidine-sulphinic acids, and silane compounds. Chemical sensitization may also be performed with small amounts of Ir, Rh, Ru, Pb, Cd, Hg, Tl, Pd, Pt, or Au. One of these chemical sensitization methods or a combination thereof may be used.

Preferably the silver halide crystals are predigested with weakly oxidizing compounds as e.g. thiosulphonic acids before being chemically ripened. Chemical sensitization may occur in the presence of spectral sensitizers.

The grain size of the silver halide particles can be 20 determined by the Moeller Teller method in the sample containing silver halide particles is sedimented upon a filter paper, which is submerged in electrolyte together with a negative platinum needleshaped electrode and a reference electrode. The silver halide particles on the filter paper are slowly scanned individually with 25 the needle-shaped electrode, whereupon the silver halide grains are individually electrochemically reduced at the cathode. electrochemical reduction is accompanied by a current pulse, which is registered as a function of time and integrated to give the charge transfer Q for the electrochemical reduction of the silver 30 halide particle, which is proportional to its volume. From their volume the equivalent circular grain diameter of each grain can be determined and therefrom the average particle size and size distribution.

35 Binders

Colloidal binders used during the silver halide precipitation in the preparation of silver halide emulsion are hydrophilic binders such as the frequently used gelatin. Gelatin may, however, 40 be replaced in part or integrally by synthetic, semi-synthetic, or natural polymers. Synthetic substitutes for gelatin are e.g. polyvinyl alcohol, poly-N-vinyl pyrrolidone, polyvinyl imidazole,

polyvinyl pyrazole, polyacrylamide, polyacrylic acid, and derivatives thereof, in particular copolymers thereof. Natural substitutes for gelatin are e.g. other proteins such as zein, albumin and casein, cellulose, saccharides, starch, and alginates.

5 In general, the semi-synthetic substitutes for gelatin are modified natural products e.g. gelatin derivatives obtained by conversion of gelatin with alkylating or acylating agents, by grafting of polymerizable monomers on gelatin or prehardened gelatins with blocked functional groups as a consequence of this prehardening treatment, and cellulose derivatives such as hydroxyalkyl cellulose, carboxymethyl cellulose, phthaloyl cellulose, and cellulose sulphates.

The binder should of course dispose of an acceptably high number of functional groups, which by reaction with an appropriate is hardening agent can provide a sufficiently resistant layer. Such functional groups are especially the amino groups, but also carboxylic groups, hydroxy groups, and active methylene groups.

Another substitute for gelatin may be silica.

If gelatin is used as a binder gelatin may be lime-treated or 20 acid-treated. The preparation of such gelatin types has been described in e.g. "The Science and Technology of Gelatin", edited by A.G. Ward and A. Courts, Academic Press 1977, page 295 and next The gelatin may also be an enzyme-treated gelatin as described in Bull. Soc. Sci. Phot. Japan, Nº 16, page 30 (1966). 25 Preferably, use is made of photographically inert gelatin so as to add a reproducible amount of chemical sensitizers at the end of the precipitation or after flocculation or washing or redispersing the silver halide emulsion. To get a qualitatively good flocculate flocculating agents as e.g. polystyrene sulphonic acid etc. may be 30 added before or after acidifying the emulsion. Other possibilities are offered by filtration techniques e.g. dialysis, ultrafiltration etc. so that the emulsion may be washed to a desired pAg value without the requirement to be redispersed afterwards. Emulsion flocculates need to be washed out by the addition of well-35 determined amounts of demineralized water, whether or not doped with small amounts of water-soluble salts.

Spectral sensitizers

According to a fifth embodiment of the photographic material, according to the present invention, the layer containing silver halide further contains a spectral sensitizer. The spectral

sensitizer are chosen as a function of the light source, showing a high light absorption at the exposure wavelength of the light source.

Spectral sensitizers may be added partially before, partially safter or integrally after chemical sensitization with a total amount needed to reach the optimal coverage degree.

The light-sensitive silver halide emulsions may be spectrally sensitized with methine dyes such as those described by F.M. Hamer in "The Cyanine Dyes and Related Compounds", 1964, John Wiley 10 & Sons. Dyes that may be used for the purpose of spectral sensitization include cyanine dyes, merocyanine dyes, complex cyanine dyes, complex merocyanine dyes, holopolar cyanine dyes, hemicyanine dyes, styryl dyes and hemioxonol dyes. Particularly valuable dyes are those belonging to the cyanine dyes, merocyanine dyes, complex merocyanine dyes, rhodacyanine dyes.

Preferred rhodacyanine dyes for use in the photographic materials, according to the present invention, have chemical structures as described in EP-A 473 209.

Other dyes, which do not have any spectral sensitization
20 activity, or certain other compounds, which do not substantially
absorb visible radiation, may have a supersensitization effect when
they are incorporated together with said spectral sensitizing
agents into the emulsion. Suitable supersensitizers include
heterocyclic mercapto compounds containing at least one
25 electronegative substituent as described e.g. in US-A 3,457,078,
nitrogencontaining heterocyclic ring-substituted amino-stilbene compounds
as described e.g. in US-A 2,933,390 and US-A 3,635,721, aromatic

organic acid/formaldehyde condensation products as described e.g. $30\,$ in US-A 3,743,510, cadmium salts, and azaindene compounds.

Stabilizers

According to a sixth embodiment of the photographic material, according to the present invention, the layer containing silver halide further contains at least one compound for preventing the formation of fog or stabilizing the photographic characteristics during the production or storage of photographic elements or during the photographic treatment thereof. Many known compounds may be added as fog-inhibiting agent or stabilizer to the silver halide emulsion. Suitable examples are i.a. the heterocyclic nitrogen-containing compounds such as benzothiazolium salts,

nitroimidazoles, nitrobenzimidazoles, chlorobenzimidazoles, bromobenzimidazoles, mercaptothiazoles, mercaptobenzothiazoles, mercaptobenzimidazoles, mercaptothiadiazoles, aminotriazoles, benzotriazoles (preferably 5-methyl-benzotriazole), nitrobenzo-5 triazoles, mercaptotetrazoles, in particular 1-phenyl-5-mercaptotetrazole, mercaptopyrimidines, mercaptotriazines, benzothiazoline-2-thione, oxazoline-thione, triazaindenes, tetrazaindenes and pentazaindenes, especially those described by Birr in Z. Wiss. Phot. 47 (1952), pages 2-58, triazolopyrimidines such as those 10 described in GB-A 1,203,757, GB-A 1,209,146, JN 75-39537, and GB-A 1,500,278, and 7-hydroxy-s-triazolo-[1,5-a]-pyrimidines as described in US 4,727,017, and other compounds such as benzenethiosulphonic acid, benzenethiosulphinic acid, benzenethiosulphonic acid amide. Other compounds that may be used as fog-inhibiting 15 compounds are metal salts such as e.g. mercury or cadmium salts and the compounds described in Research Disclosure N° 17643 (1978), Chaptre VI.

Preferred stabilizers added to the emulsion in accordance with this invention are e.g. 4-hydroxy-6-methyl-1,3,3a,7-tetraazaindene and 1-phenyl-5- mercaptotetrazole, thioether substituted 1-phenyl-5-mercaptotetrazoles as described in EP-A 53 851 being more preferable, especially if they have a solubilizable group as those described in Research Disclosure No. 24236 (1984).

The fog-inhibiting agents or stabilizers can be added to the silver halide emulsion prior to, during, or after the ripening thereof and mixtures of two or more of these compounds may be used.

Support

According to a second embodiment of the photographic material, according to the present invention, the support is transparent or translucent. Thin flexible supports of transparent resin film are preferred, e.g. of a cellulose ester, e.g. cellulose triacetate, polypropylene, polycarbonate or polyester, e.g. poly(ethylene serious terephthalate). The support may be in sheet, ribbon or web form and subbed if need be to improve the adherence to the thereon coated thermosensitive element. The support may be dyed or pigmented to provide a transparent coloured background for the image.

Subbing layers and subbing layer systems

According to a third embodiment of the photographic material, according to the present invention, said support is provided with at least one subbing layer or subbing layer system.

According to a fourth embodiment of the photographic material, according to the present invention, said support is provided with at least one subbing layer or subbing layer system and at least one subbing layer or subbing layer system contains at least one compound represented by said formula (I), at least one compound represented by said formula (II) or a mixture of at least one compound represented by said formula (I) and at least one compound represented by said formula (II).

The term subbing layer system refers to more than one layer fulfilling the function of subbing, subbing meaning provision of a means of providing adhesion of a functional layer to a support. For example, in photothermographic materials a combination of two layers is often used to provide adhesion of a photographic silver halide and gelatin-containing emulsion layer to a poly(ethylene terephthalate) support, the layer adjacent to the poly(ethylene terephthalate) support often comprising a polymer latex, e.g. a terpolymer latex of vinylidene chloride/methyl acrylate/itaconic acid (88/10/2 by weight), colloidal silica and anionic surfactants, and the second layer in the subbing layer system often comprising gelatin, colloidal silica and anionic surfactants.

It is preferred that at least one compound represented by said formula (I), at least one compound represented by said formula (II) or a mixture of at least one compound represented by said formula (I) and at least one compound represented by said formula (II) be present in at least one and preferably all the layers of a subbing layer system used in photographic materials. This is not only because of the photographically inert nature of compounds represented by formula's (I) and (II) and the absence of photographically active impurities, but also because of the improved wettability of subbing layers and of the outermost layer of subbing layer systems resulting in improved overcoatability and faster coating compared with alternative surfactants such as ULTRAVON™ W from Ciba-Geigy.

Preferred additional ingredients for the subbing layer used in accordance with the present invention are a polymer latex and polyethylene wax. Particularly preferred polymer latexes for use in the subbing layer of the present invention are producible with

monomers selected from the group consisting of acrylates, methacrylates, vinyl esters, acrylic acid, methacrylic acid, itaconic acid, vinylidene chloride, polyisocyanates, aromatic polycarboxylic acids and polyols.

Suitable additional ingredients for use in the subbing layer of the photographic material, according to the present invention, are:

- sorbitol;
- a terpolymer latex of vinylidene chloride/methyl acrylate/itaconic acid (88/10/2 by weight);
- gelatin e.g. K 18435, a calcium-free medium viscosity gelatin from DGF STOESS;
- microcrystalline polyethylene wax e.g. MOBILCER™ Q from Mobil Oil;
- polymethylmethacrylate particles;
- silica e.g. KIESELSOL 100F and KIESELSOL 300F, 30% by weight aqueous dispersions of colloidal silica from BAYER, and, a 30% aqueous dispersion of colloidal silica from BAYER; and
- additional non-ionic and anionic surfactants.

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It is particularly preferred to post-stabilize latexes such a terpolymer latex of vinylidene chloride/methyl acrylate/itaconic acid (88/10/2 by weight) with at least one compound represented by said formula (I), at least one compound represented by said formula (II) or a mixture of at least one compound represented by said formula (II) and at least one compound represented by said formula (II) e.g. a mixture of Compounds 75 and 78.

Coating techniques

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The coating of any layer of the substantially light-insensitive thermographic recording material used in the present invention may proceed by any coating technique e.g. such as described in Modern Coating and Drying Technology, edited by Edward D. Cohen and Edgar B. Gutoff, (1992) VCH Publishers Inc., 220 East 23rd Street, Suite 909 New York, NY 10010, USA. Coating may proceed from aqueous or solvent media with overcoating of dried, partially dried or undried layers.

Industrial application

The compounds according to the present invention are used as surfactants in the subbing layers and subbing layer configurations of photographic materials, in the subbing layers, subbing layer configurations and protective layers of substantially light-insensitive thermographic recording materials and in the post-stabilization of polymer latexes.

The invention is illustrated hereinafter by way of comparative examples and invention examples. The percentages and ratios given in these examples are by weight unless otherwise indicated.

Synthesis of compounds represented by formula's (I) and (II) $\it 15$

General synthesis route for Compounds 2, 4, 10, 14 etc.:

The sodium salt of 2-mercapto-benzimidazole-5-sulphonic acid was S-alkylated in the presence of DIPEA (N,N-diisopropylethylamine) as 20 base in dimethyl acetamide by reaction with the corresponding alkyl bromide by stirring overnight at 52°C. In this way alkylation could be carried out selectively at the mercapto-group and could be suppressed at the 1-position. A yield of up to 96% of compound 10 was obtained in the case of cetyl bromide.

Synthesis of Compound 10:

1728g of the monosodium salt of 2-mercapto-benzimidazole-5-sulphonic acid and 3150 mL of dimethyl acetamide were added to a 10 litre vessel provided with a compressed air stirrer, a dropping funnel and a reflux condenser was placed in an oil bath. 1359 mL of DIPEA were then added to this heterogeneous mixture with stirring and the light-brown suspension heated to 40°C. 2382g of cetyl bromide was added dropwise and the mixture heated to 52°C. There was no increase in temperature during this step. The reaction was carried out with stirring at 52°C for 20 hours after which the reaction was virtually complete. The mixture was then transferred to a 20 litre vessel, cooled to room temperature and 6 L of acetone was added with stirring and the stirring continued for 1 hour after the addition was completed. A thick suspension was obtained, which is relatively difficult to stir. The product was then filtered off, twice washed with 800 mL of a 1:2 mixture of dimethyl

acetamide/acetone, twice washed with 1400 mL of a 1:3 mixture of dimethyl acetamide/acetone, washed four times with 1200 mL of acetone and finally dried in a forced air drying cupboard at 45°C for 2 days. 2.53 kg of Compound 10 (sodium salt of 2-5 thiohexadecyl-benzimidazole-5-sulphonic acid) was obtained corresponding to a yield of 89% and contained 4 mol% of dimethyl acetamide and 7 mol% of DIPEA.

Synthesis of a mixture of the structural isomers Compound 43 and 10 Compound 46:

1190g of Compound 10 (sodium salt of 2-thiohexadecyl-benzimidazole-5-sulphonic acid) and 3890 mL of dimethyl acetamide were added to a 10 litre vessel provided with a compressed air stirrer, a dropping 15 funnel and a reflux condenser was placed in an oil bath. 103.9 g of 97% sodium hydroxide were then added with stirring and the mixture The heat source was then removed and 252.4 \mbox{mL} of heated to 80°C. butanesultone added over a period of 5 minutes, whereupon the temperature increased to 94°C. After addition of a third of this 20 quantity of butanesultone a white precipitate is formed and the mixture becomes more difficult to stir after addition was The reaction mixture was then cooled to 50°C and 5170 mL of acetone added with stirring. The product precipitates out and the suspension becomes more difficult to stir. The product was 25 then filtered off, washed with 2 L of a 1:3 mixture of dimethyl acetamide/acetone, stirred with 14 L of a 1:3 mixture of dimethyl acetamide/acetone, filtered again, twice washed with 4 L of a 1:3 mixture of dimethyl acetamide/acetone, washed 6 times with 2 L of acetone and then dried to constant weight in a forced air drying The product a mixture of the structural isomers: 30 cupboard at 45°C. Compound 43 (2-thiohexadecyl, 3-sulphobutyl-benzimidazole-5sulphonic acid sodium salt) and Compound 46 (2-thiohexadecyl,3sulphobutyl-benzimidazole-6-sulphonic acid sodium salt) was obtained in a yield of 95%.

Separation of Compound 43 (2-thiohexadecyl,3-sulphobutyl-benzimidazole-5-sulphonic acid sodium salt) and Compound 46 (2-thiohexadecyl,3-sulphobutyl-benzimidazole-6-sulphonic acid sodium salt) could be realized by working up the product before adding acetone to the reaction mixture. After filtration, washing and treatment with warm dimethyl acetamide almost pure Compound 43 (2-thiohexadecyl,3-sulphobutyl-benzimidazole-5-sulphonic acid sodium salt) was isolated. The second structural isomer, Compound 46 (2-

thiohexadecyl, 3-sulphobutyl-benzimidazole-6-sulphonic acid sodium salt) was extracted from the filtrate by adding acetone.

Ingredients used in the EXAMPLES:

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ULTRAVON W = a sodium arylsulfonate surfactant from Ciba-Geigy ARKOPON T = a 40% concentrate of a sodium salt of N-methyl-N-2-sulfoethyl-oleylamide from CLARIANT ARKOPAL $^{\text{M}}$ N060 = a nonylphenylpolyethylene-glycol from CLARIANT

NIAPROOF ANIONIC™ 4 = a 27% concentrate of a sodium 1-(2'-ethylbutyl)-4-

ethylhexylsulphate from NIACET

FLUORAD $^{\text{ms}}$ FX1005 = ammonium salt of perfluoro-octanoic acid from 3M

SURF 09 = a 1:1 mixture of Compound 75 and Compound 78

K 18114 = a gelatin from DGF STOESS

antihalo dye =

COMPARATIVE EXAMPLES 1 to 3 and INVENTION EXAMPLE 1

The post-stabilization of a 30% by weight terpolymer latex of vinylidene chloride/methyl acrylate/itaconic acid (88/10/2 by weight) was investigated in an accelerated stability test at 60°C in a drying cupboard and an autocoagulation test at 80°C in a drying cupboard with different surfactants (see above). The results of these tests are shown in Table 1:

SURF 09, a 1:1 mixture of Compound 75 and Compound 78 exhibited significantly better post-stabilization behaviour compared with other surfactants including ULTRAVON™ W.

Table 1:

Compar-	Anionic sur	factant	time after which	time to auto-
ative	type	quantity	settling first	coagulation in
example		in g/100g	observed in stability	autocoagulation
nr		latex	test at 60°C [h]	test at 80°C [h]
1	none	-	14	8.5
2	ARKOPON™ T	0.78	254	36.5
3	ULTRAVON™ W	1.09	94	17.5 to 26.5
Inven-		 -		
tion				
example				
nr				
1	SURF 09	0.78	> 254	> 48

COMPARATIVE EXAMPLES 4 to 6 and INVENTION EXAMPLES 2 to 4

The subbed-supports used in the overcoatability experiments of COMPARATIVE EXAMPLES 4 to 6 and INVENTION EXAMPLES 2 to 4 were prepared by coating both sides of a 350 µm thick poly(ethylene terephthalate) sheet already stretched in the length direction as an aqueous dispersion which after drying and transverse stretching produced a 100 µm thick support coated with the following conductive layer composition expressed as the coating weights of the ingredients present, being the first layer in the subbing layer system:

terpolymer latex of vinylidene chloride/methyl acrylate/itaconic acid (88/10/2):

 147mg/m^2 16mg/m^2

colloidal silica (KIESELSOLTM 100F from BAYER):

 25mg/m^2

MERSOLAT H80, a sodium hexadecyl-sulfonate from BAYER

 0.7mg/m^2

The second layer of the subbing layer system was then applied as an aqueous dispersion to both sides of the 100 µm thick poly(ethylene terephthalate) support, which after drying at 130°C produced the following composition expressed as the coating weights of the ingredients present:

gelatin (K 18435):

sorbitol

 190mg/m^2

colloidal silica (KIESELSOL™ 300F):

 170mg/m^2

3.2 μm polymethyl methacrylate latex particles:

 $1mg/m^2$

# 2-methyl-2,4-pentanediol:	11mg/m²
# trimethylolpropane	5.6mg/m^2
# ARKOPAL™ N060:	3.3mg/m^2
# an anionic surfactant	6.7mg/m^2

These two layers together form the subbing layer systems of COMPARATIVE EXAMPLE 4 and INVENTION EXAMPLE 2.

The overcoatability of these subbing layer systems was sevaluated with an aqueous antihalation layer coating dispersion with the composition after drying of:

```
# gelatin (K 18114):
                                                                   3100 \text{mg/m}^2
# colloidal silica (KIESELSOL™ 300F):
                                                                    590 \text{mg/m}^2
# terpolymer latex of methyl acrylate/acrylic
                                                                   1400 \text{mg/m}^2
acid/tetra-allyloxyethane (37/46.5/16.5):
# antihalo dye (see above):
                                                                    100 \text{mg/m}^2
# MOBILCER™ Q, a microcrystalline polyethylene wax from
                                                                      2.5 \text{mg/m}^2
Mobil Oil:
# glyoxal (HCOHCO) as hardener:
                                                                    72mq/m^2
# 7.5 \mum polymethyl methacrylate latex particles:
                                                                    28mg/m^2
# ARKOPON™ T:
                                                                     6mg/m^2
# NIAPROOF ANIONIC 4:
                                                                     1 \text{mg/m}^2
# FLUORAD™ FX1005:
                                                                     1.5 \text{mg/m}^2
```

The results obtained with a slide hopper (cascade) coating machine 10 are given in Table 2 below:

Table 2:

	T	r	T	<u> </u>
Compar-	Anionic surfactant	Coating	Minimum vacuum	Coating length in cm
ative	in second layer of	speed	in machine to	needed to remedy
example	subbing layer	(m/min)	obtain coating	coating faults e.g.
nr	system		[Pa]	induced by tape splice
4	ULTRAVON™ W	180	50	42
5	ULTRAVON™ W	220	80	9*
6	ULTRAVON™ W	250	360	225*
Inven-				
tion				
example				
nr				
2	SURF 09	180	60	25
3	SURF 09	220	50	9
4	SURF 09	250	120	34

^{*} coating fault not remedied at edges

It is clear from the results in Table 2, that the use of SURF 09 as an anionic surfactant in the second (outermost) layer of the subbing layer system instead of ULTRAVON™ W substantially improved the overcoatability of the subbing layer system with the antihalation layer coating dispersion, particularly at coating speeds of 220 to 250 m/minute where otherwise coating faults were not remedied at the edges of the coating.

COMPARATIVE EXAMPLES 7 and 8 and INVENTION EXAMPLE 5

The subbed-supports used in the photographic materials of COMPARATIVE EXAMPLES 7 and 8 and INVENTION EXAMPLE 5 were prepared as described for the overcoatability experiments of COMPARATIVE EXAMPLES 4 to 6 and INVENTION EXAMPLES 2 to 4 except that MERSOLAT[™] 15 H80 in the first layer was replaced by ULTRAVON[™] W or ARKOPON[™] T or SURF 09. The surfactants used in the first and second layers of the subbing layer system used in the photographic materials of COMPARATIVE EXAMPLES 7 and 8 and INVENTION EXAMPLES are given in Table 3.

The photographic materials of COMPARATIVE EXAMPLES 7 and 8 and INVENTION EXAMPLE 5 were prepared by coating onto both sides of the above-described support the same silver halide emulsion as that used in the blue-sensitive universal X-ray film type CP-BU produced The material before and after heating for 36 h at by AGFA-GEVAERT. 25 57°C at 34% relative humidity was exposed through a density wedge (continuously varying carbon-coated wedge (constant 0.15) by visible light a from projection lamp (130V; 250W - having an exposure voltage of 85V) during 0.1 s at a distance of 1.7 m from the film, a densitometric filter with a density of 0.30 and a 30 "Corning filter 5850" as a blue filter with a density of 2.64 (measured with a Macbeth TR 924 densitometer). The light sensitivity, S, is the log of the light exposure in $\mu J/cm^2$ needed to obtain a density of 1.00 above fog density, which is lower for materials with a higher sensitivity to light, and the minimum 35 density was determined from the wedge patterns obtained after development at 33°C for 90 seconds in a G1381 M 6/5 developer produced by AGFA-GEVAERT. The sensitivities and minimum densities Dmin obtained for the photographic materials of COMPARATIVE EXAMPLES 7 and 8 and INVENTION EXAMPLE 5 before and after heating 40 for 36 h at 57°C at 34% relative humidity are summarized in Table 3.

Table 3:

Compar-	Anionic surfactant		Anionic surfactant		fresh		material	
ative	in 1st layer of		in 2nd layer of		material		after 36h/	
example	subbing layer system		subbing layer system				57°C/34%RH	
nr	type	quantity [mg/m²]	type	quantity [mg/m²]	Dmin	S	Dmin	S
7	ULTRAVON™W	4.0	ULTRAVON™W	6.7	0.064	1.66	0.145	1.67
8	ARKOPON™T	5.0	ARKOPON™T	6.7	0.061	1.66	0.146	1.66
Inven-								
tion								
example								
nr								
5	SURF 09	4.0	SURF 09	6.7	0.058	1.66	0.124	1.65

From the results in Table 3, it is clear that after heating for 36

5 h at 57°C at 34% relative humidity the photographic material of INVENTION EXAMPLE 5 with SURF 09 in both the first and outermost (second) layer of the subbing layer system resulted in a significantly lower increase in Dmin than the photographic materials of COMPARATIVE EXAMPLES 7 and 8 with ULTRAVON™ W and ARKOPON™ T respectively in both the first and outermost (second) layer of the subbing layer system, indicating the lower photographic activity of SURF 09 compared with ULTRAVON™ W and ARKOPON™ T.

15 The present invention may include any feature or combination of features disclosed herein either implicitly or explicitly or any generalisation thereof irrespective of whether it relates to the presently claimed invention. In view of the foregoing description it will be evident to a person skilled in the art that various 20 modifications may be made within the scope of the invention.

CLAIMS

1. A compound represented by formula (I):

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a compound represented by formula (II):

$$M \xrightarrow{O \setminus \bigcup_{S} \\ O \setminus \bigcup_{N} \\ N} R^{1}$$

or a mixture of at least one compound represented by formula (I) with at least one compound represented by formula (II), wherein M is hydrogen, an alkali atom or an ammonium group; R^1 is hydrogen,

10 a $-(CH_2)_mSO_3M$ group or a MO_3S group; R^2 is an alkyl-, alkenyl- or alkynyl- group having 6 to 25 carbon atoms; and m is an integer between 1 and 5.

- 2. Compound according to claim 1, wherein R^1 is a $-(CH_2)_mSO_3M$ group and n is 12 to 24.
 - 3. Compound according to claim 1, wherein R^1 is a $-(CH_2)_mSO_3M$ group and n is 12 to 16.
- 20 4. Use of at least one compound represented by formula (I):

$$\begin{array}{c|c}
& & & \\
& & & \\
M & & \\$$

at least one compound represented by formula (II):

$$M \xrightarrow{O \setminus \prod_{s \in S} \prod_{s \in$$

or a mixture of at least one compound represented by said formula (I) and at least one compound represented by said formula (II), wherein M is hydrogen, an alkali atom or an ammonium group; R^1 is

hydrogen, a $-(CH_2)_mSO_3M$ group or a group; R^2 is an alkyl-, alkenyl- or alkynyl- group having 6 to 25 carbon atoms; and m is an integer between 1 and 5, as a surfactant.

5. A photographic material comprising a support and at least one layer containing photosensitive silver halide, characterized in that said photographic material contains at least one compound represented by formula (I):

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at least one compound represented by formula (II):

$$M \longrightarrow \bigcup_{S} \bigcup_{O} \bigcup_{N} \bigcup_{N} \bigcup_{S} \bigcup_{R^{2}} \bigcup_{S} \bigcup_{N} \bigcup_{S} \bigcup_{S} \bigcup_{N} \bigcup_{S} \bigcup_{S} \bigcup_{R^{2}} \bigcup_{S} \bigcup_{S$$

15

5

or a mixture of at least one compound represented by said formula (I) and at least one compound represented by said formula (II) as a surfactant, wherein M is hydrogen, an alkali atom or an ammonium group; R^1 is hydrogen, a -(CH₂)_mSO₃M group or a

20

group; R² is an alkyl-, alkenyl- or alkynyl- group having 6 to 25 carbon atoms; and m is an integer between 1 and 5.

- 6. Photographic material according to claim 5, wherein said support is provided with at least one subbing layer or subbing layer system.
- one subbing layer or subbing layer system contains at least one compound represented by the above-mentioned formula (I), at least one compound represented by the above-mentioned formula (II) or a mixture of at least one compound represented by the above-mentioned by the above-mentioned formula (I) and at least one compound represented by the above-mentioned formula (II).

ABSTRACT

NOVEL SURFACTANTS

5 A compound represented by formula (I):

$$\begin{array}{c|c}
& & & \\
& & & \\
M & & \\
M$$

a compound represented by (II):

10

or a mixture of at least one compound represented by formula (I) with at least one compound represented by formula (II), wherein M is hydrogen, an alkali atom or an ammonium group; R^1 is hydrogen, a

-(CH₂)_mSO₃M group or a

; R^2 is an alkyl-, alkenyl- or

15 alkynyl- group having 6 to 25 carbon atoms; and m is an integer between 1 and 5; the use of at least one compound represented by the above-mentioned formula (I), at least one compound represented by the above-mentioned formula (II) or a mixture of at least one compound represented by the above-mentioned formula (I) and at least one compound represented by the above-mentioned formula (II) as a surfactant; and a photographic material comprising a support and a layer containing photosensitive silver halide, characterized in that the photographic material contains at least one compound represented by the above-mentioned formula (I), at least one compound represented 25 by the above-mentioned formula (II) or a mixture of at least one compound represented by the above-mentioned formula (II) and at least one compound represented by the above-mentioned formula (II).